

ABSTRACT OF THE DISCLOSURE

Organoamino-Polysiloxanes for Deposition of Silicon-Containing Films

5 Organoamino-polysiloxanes, which have at least three silicon atoms, oxygen atoms, as well as an organoamino group, and methods for making the organoamino-polysiloxanes are disclosed. Methods for depositing silicon and oxygen containing films using the organoamino-polysiloxanes are also disclosed.

10 [No figure]